

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	Mail Stop AF
Adrien Dromard et al.)	Group Art Unit: 1793
Application No.: 10/583,417)	Examiner: Richard M. Rump
Filed: April 26, 2007)	Confirmation No.: 3689
For: HIGHLY-STRUCTURED SILICA)	
HAVING A LOW WATER UPTAKE,)	
PREPARATION METHOD)	
THEREOF AND USES OF THE)	
SAME)	

AMENDMENT PURSUANT TO 37 C.F.R. §1.116

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated November 5, 2009, please amend the
above-identified patent application as follows: